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(12) **United States Design Patent**
Chiquet

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(54) **PROTECTIVE FACE MASK**

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(CH)

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(**) Term: **15 Years**

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(51) **LOC (13) Cl.** **29-02**

(52) **U.S. Cl.**
USPC **D24/110.1**

(58) **Field of Classification Search**
USPC D24/110.1–110.3; D29/104–110
CPC A41D 13/11
See application file for complete search history.

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Primary Examiner — Darcey E Gottschalk

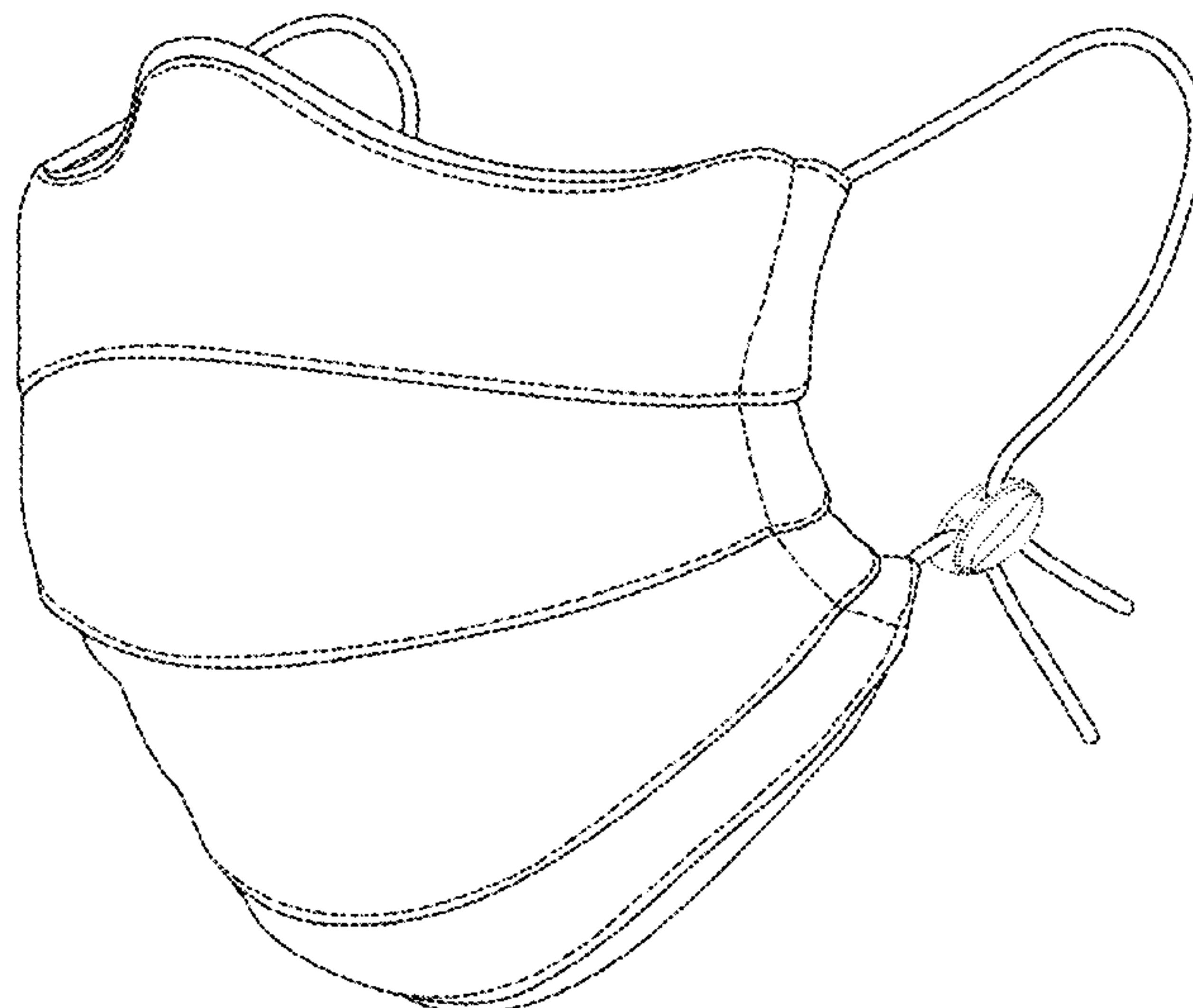
(57) **CLAIM**

The ornamental design for a protective face mask, as shown and described.

DESCRIPTION

1. Protective face mask
1.1 is a perspective view of our new design for a protective face mask.
1.2 is a front view of **1.1**.
1.3 is a back view of **1.1**.
1.4 is a left view of **1.1**.
1.5 is a right view of **1.1**.
1.6 is a top view of **1.1**.
1.7 is a bottom view of **1.1**.
The dash-dash lines in the drawing represent stitching, which is part of the claimed design. The features shown in dot-dot lines show portions of a protective face mask that form no part of the claimed design.

1 Claim, 7 Drawing Sheets



(56)

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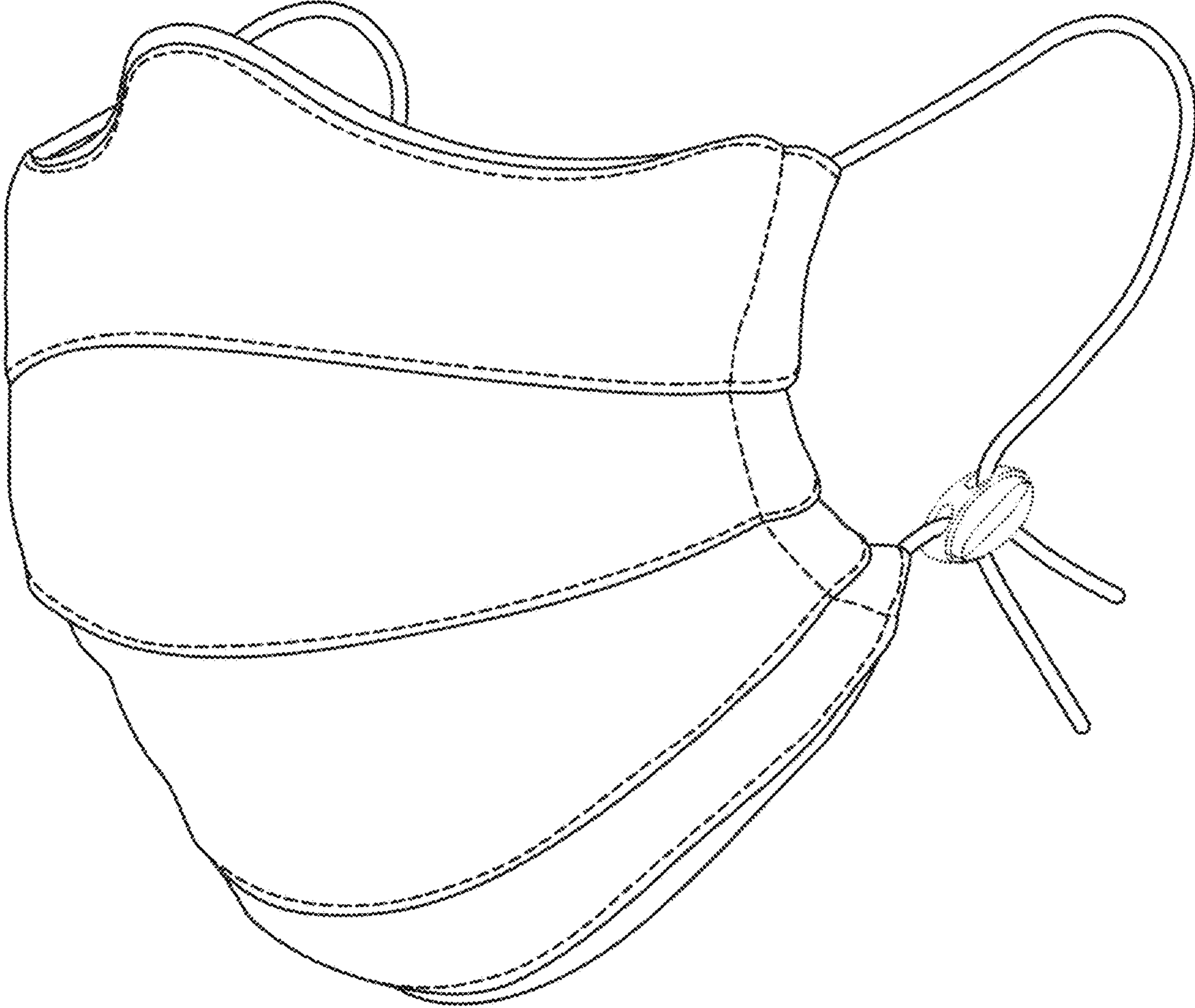
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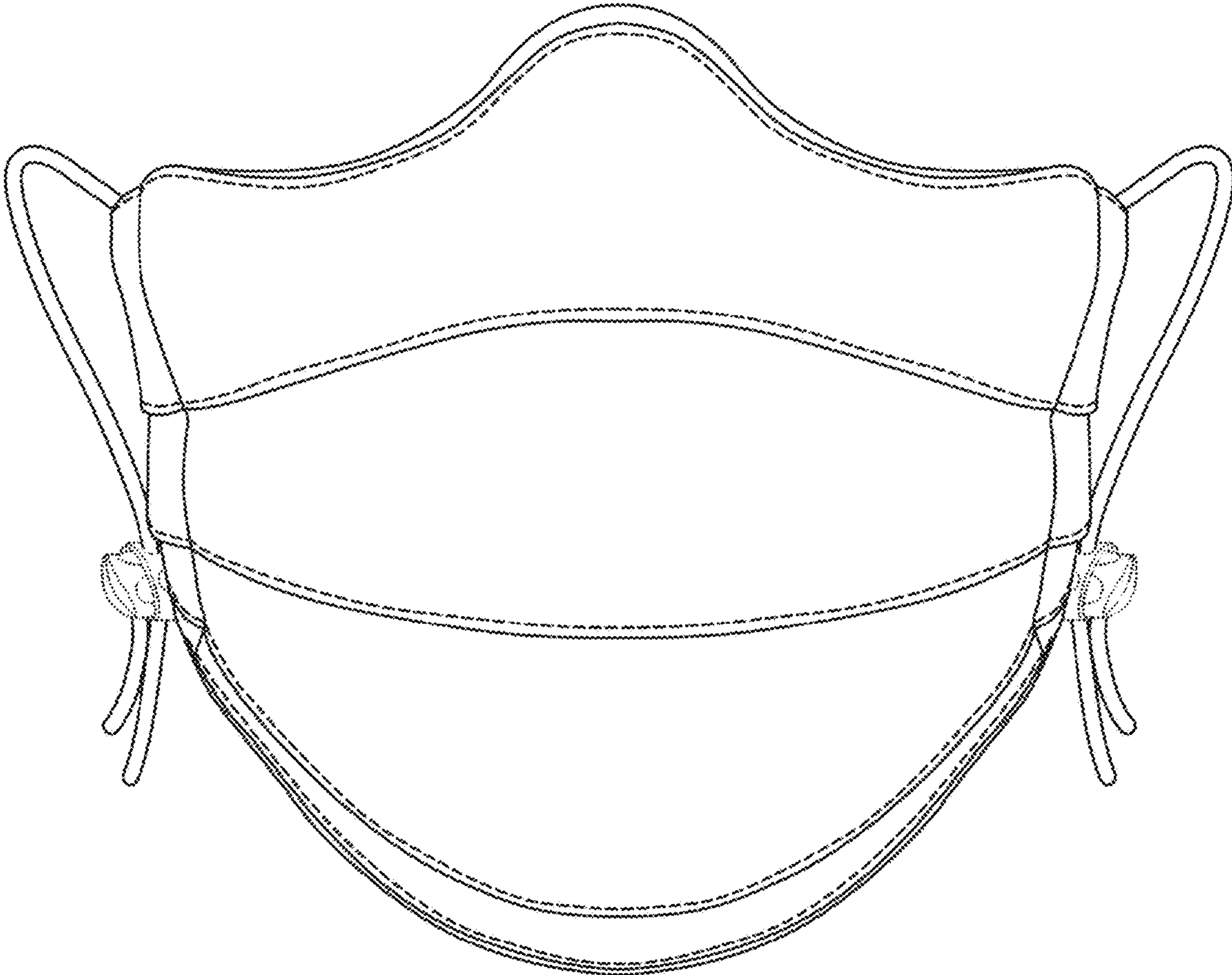
Predecessor model, older mask, press release photo dated Apr. 16, 2020.

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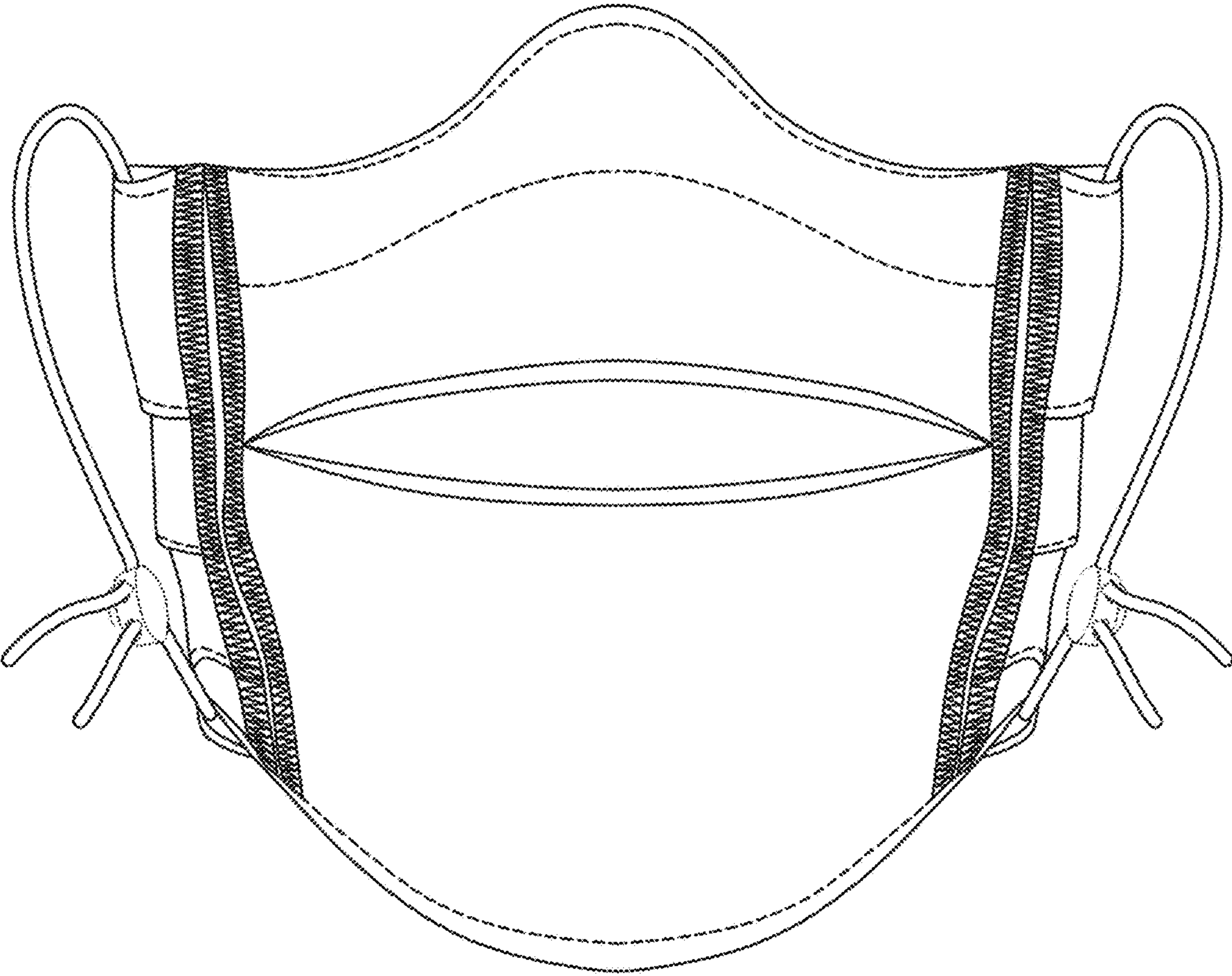
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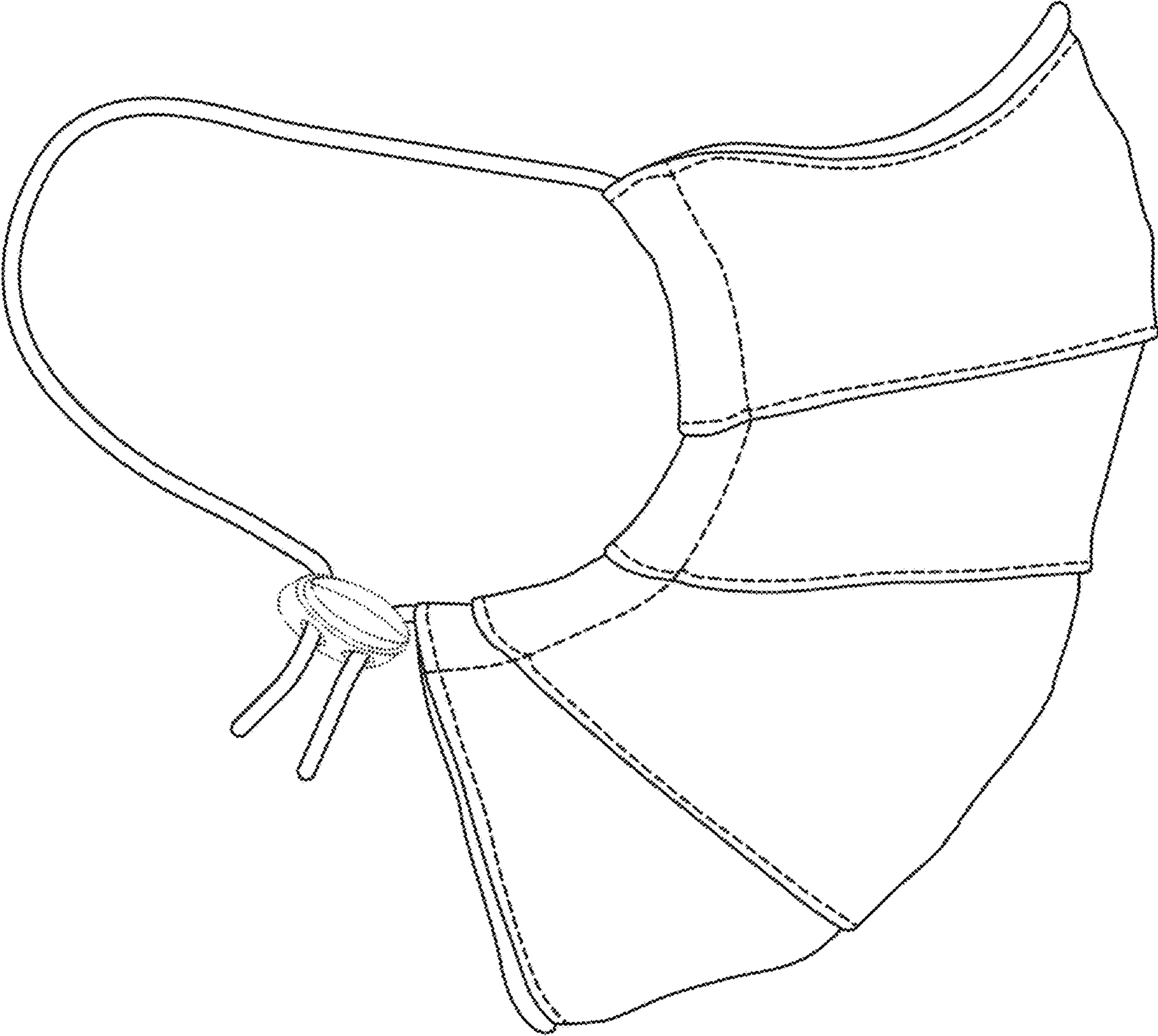
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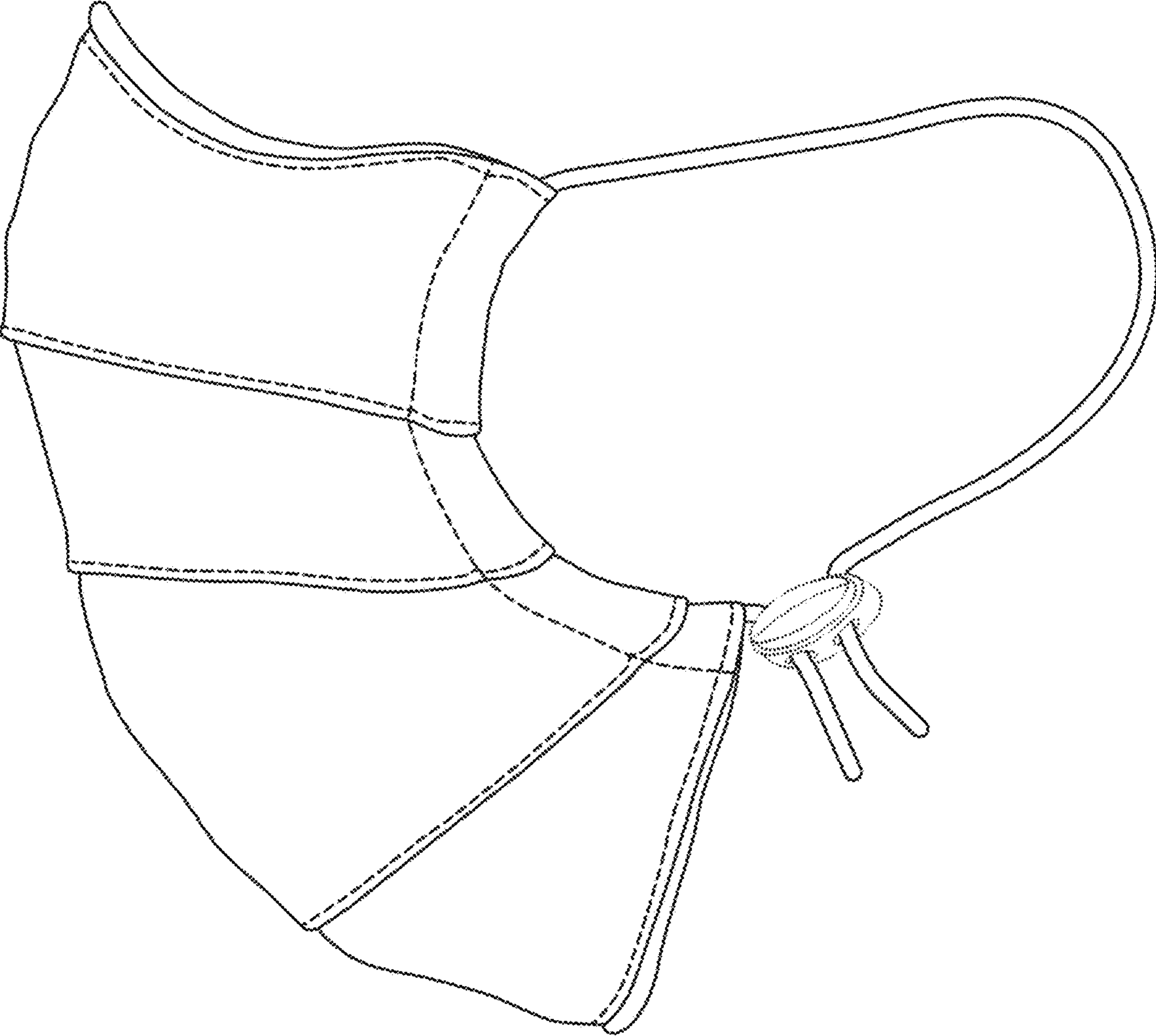
1.3



1.4



1.5



1.6



1.7

